

Supplemental Document

A ReaxFF Study for Hacac Interaction on Al₂O₃ Surface in Area-Selective ALD

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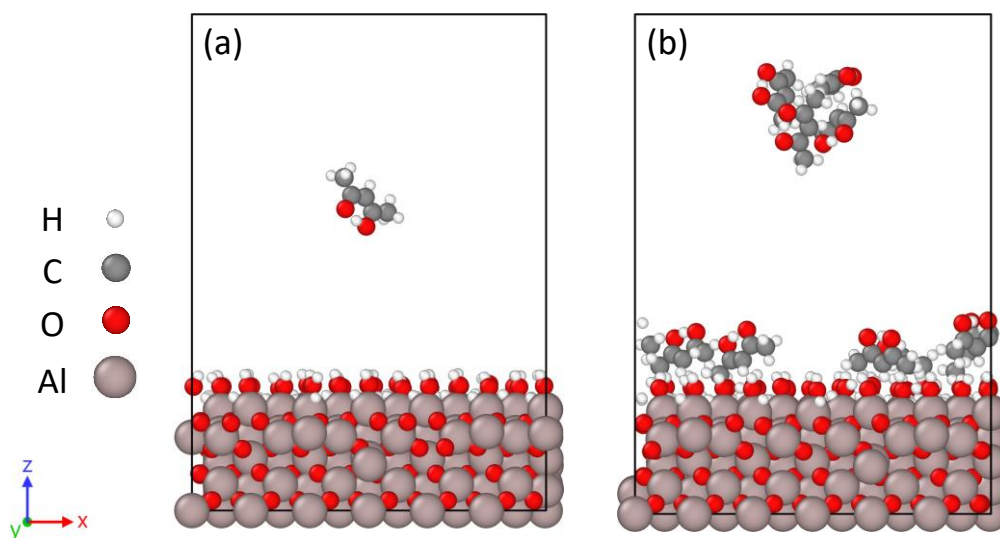


Figure. The snapshots of the front view at (a) the initial system showing the first Hacac in the gas phase and (b) the final system showing physisorbed Hacac inhibitor molecules on the surface and condensed Hacac in the gas phase.